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APPLICATION NO. FILING DATE FIRST NAMED INVENTOR ATTORNEY DOCKET NO. CONFIRMATION NO. 10/019,407 03/25/2002 Yoshinobu Kimura 520,41003 X00 3893

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EXAMINER
SCHILLINGER, LAURA M

ART UNIT PAPER NUMBER

DATE MAILED: 08/05/2005

2813

Please find below and/or attached an Office communication concerning this application or proceeding.

		Application No.	Applicant(s)
Office Action Summary		10/019,407	KIMURA ET AL.
		Examiner	Art Unit
		Laura M. Schillinger	2813
The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply			
A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailling date of this communication. - If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely. - If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication. - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).			
Status			
1)⊠	Responsive to communication(s) filed on 25 M	ay 2005.	
2a)⊠	This action is FINAL . 2b) ☐ This	action is non-final.	
3)	Since this application is in condition for allowance except for formal matters, prosecution as to the ments is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.		
Disposition of Claims			
5)□ 6)⊠ 7)□	 Claim(s) 1-6 and 8-20 is/are pending in the application. 4a) Of the above claim(s) 1,2,5,6 and 8-20 is/are withdrawn from consideration. Claim(s) is/are allowed. Claim(s) 3 and 4 is/are rejected. Claim(s) is/are objected to. Claim(s) are subject to restriction and/or election requirement. 		
Application Papers			
9) The specification is objected to by the Examiner.			
10)	10)☐ The drawing(s) filed on is/are: a)☐ accepted or b)☐ objected to by the Examiner.		
	Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).		
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d). 11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.			
Priority under 35 U.S.C. § 119			
12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received.			
Attachment(s)			
1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 4) Interview Summary (PTO-413) Paper No(s)/Mail Date.			
3) Inform	e of Draitsperson's Patent Drawing Review (PTO-946) mation Disclosure Statement(s) (PTO-1449 or PTO/SB/08) r No(s)/Mail Date		atent Application (PTO-152)

DETAILED ACTION

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Election/Restrictions

Claims 1-2,5, 6, and 8-20 are withdrawn from further consideration pursuant to 37 CFR 1.142(b) as being drawn to a nonelected claims, there being no allowable generic or linking claim. Election was made without traverse in the reply filed on 2/25/05.

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 3-4 are rejected under 35 U.S.C. 103(a) as being unpatentable over Yamazaki (*730), and further in view of Mitlitsky et al (*404).

Yamazaki teaches the following claimed limitations with respect to claims 3 and 4:

3. A semiconductor device comprising plural transistors formed in a polycrystalline semiconductor thin film, wherein the polycrystalline semiconductor thin film is formed by a plurality of laser irradiation steps, (Abs., lines: 12-16) the number of crystal grains with the number of closest crystal grains of 6 is greatest among plural crystal grains that form the polycrystalline semiconductor thin film(Col.8, lines: 25-45 and Fig.2A).

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4. A semiconductor device as defined in claim 3, wherein the roughness of the grain the polycrystalline boundaries on the surface of semiconductor thin film is 5 nm or less(Col.6, lines: 5-10).

However, Yamazaki teaches that to heat last laser irradiation results in a monocrystalline film and fails to teach the limitation of claim 3, "wherein the laser irradiation steps are carried out so that after the last laser irradiation step the number of crystal grains with the number of closest crystal grains of 6 is greatest among plural crystal grains".

However, as Mitlitsky et al teaches that lasers may be used to form polycrystalline thin films at lower temperatures than conventional heating techniques (Col.10, lines: 10-20).

It would have been obvious to one of ordinary skill in the art at the time the invention was made to modify Yamazaki's teachings to use a laser, rather than conventional heating, to form a polysilicon layer as taught by Mitlitsky because as Mitlitsky teaches, laser annealing prevents damage to underlying silicon substrates and still produces a multi-grained crystalline film (Col.1, lines: 10-25).

Conclusion

Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, THIS ACTION IS MADE FINAL. See MPEP § 706.07(a).

Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

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A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Laura M. Schillinger whose telephone number is (571) 272-1697. The examiner can normally be reached on M-T, R-F 7:00-5:00.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Carl W. Whitehead, Jr. can be reached on (571) 272-1702. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Laura Mfaluly

Laura M Schillinger Primary Examiner Art Unit 2813 Application/Control Number: 10/019,407

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